

**AMENDMENTS TO THE ABSTRACT**

Please substitute the following paragraph(s) for the abstract now appearing in the currently filed specification:

--A sufficiently high-transparent light transmitting substrate with a transparent conductive film, which is a light transmitting substrate with a transparent conductive film, includes a light transmitting substrate and a continuous transparent conductive film having a thickness of 12 to 2 nm formed on the light transmitting substrate. The transparent conductive film is made of an aggregate of columnar single crystals and has a maximum surface roughness within a range from 1 to 20 nm. It also has an average surface roughness within a range from 0.1 to 10 nm and is a thin film made of a tin-doped indium oxide. Tin atoms are uniformly distributed in the thin film made of the tin-doped indium oxide.--